

Application No. 10/717,268
Amendment dated May 10, 2006
Reply to Office Action of February 10, 2006

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/717,268
Filed: November 19, 2003
Applicant: Jozef Brcka et al.
Art Unit: 1763
Examiner: Rakesh Kumar Dhingra
Title: PLASMA PROCESSING SYSTEM WITH LOCALLY-EFFICIENT
INDUCTIVE PLASMA COUPLING
Attorney Docket: TAZ-248

VIA ELECTRONIC FILING

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE

In response to the Office Action of February 10, 2006, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this Amendment.

Amendments to the Drawings begin on page 6 of this Amendment and include both an attached replacement sheet and an annotated sheet showing changes.

Amendments to the Claims are reflected in the listing of claims, which begins on page 7 of this Amendment.

Remarks begin on page 13 of this Amendment.

An **Appendix** including amended drawing figures is attached following page 16 of this Amendment.